

N AND P-CHANNEL ENHANCEMENT MODE POWER MOSFET N 加 P 沟道增强型 MOS 管

N-CH V_{DS} = 40V

R_{DS(ON)}, V_{GS}@10V, I_{DS}@6.0A = 31mΩ

R_{DS(ON)}, V_{GS}@4.5V, I_{DS}@5.0A = 45mΩ

P-CH V_{DS} = -40V

R_{DS(ON)}, V_{GS}@-10V, I_{DS}@-5.0A = 45mΩ

R_{DS(ON)}, V_{GS}@-4.5V, I_{DS}@-4.0A = 63mΩ

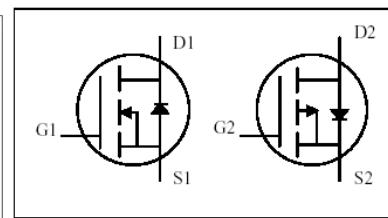
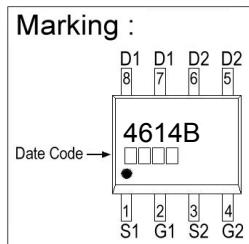
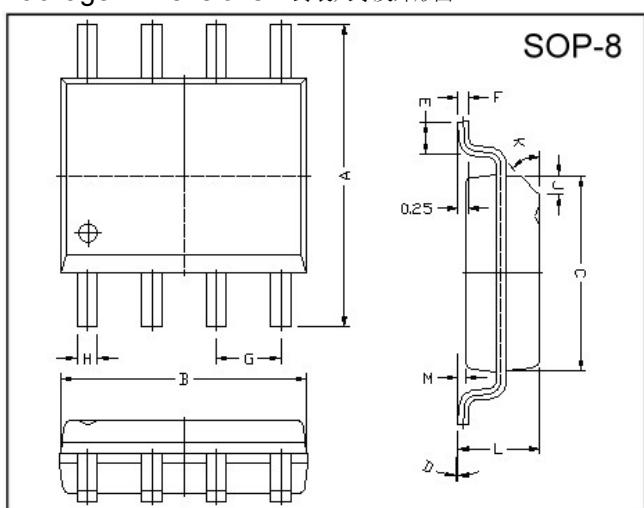
Features 特性

Advanced trench process technology 高级的加工技术

High Density Cell Design For Ultra Low On-Resistance 极低的导通电阻高密度的单元设计

Improved Shoot-Through FOM 改良的成形工艺

Package Dimensions 封装尺寸及外形图



REF.	Millimeter		REF.	Millimeter	
	Min.	Max.		Min.	Max.
A	5.80	6.20	M	0.10	0.25
B	4.80	5.00	H	0.35	0.49
C	3.80	4.00	L	1.35	1.75
D	0°	8°	J	0.375 REF.	
E	0.40	0.90	K	45°	
F	0.19	0.25	G	1.27 TYP.	

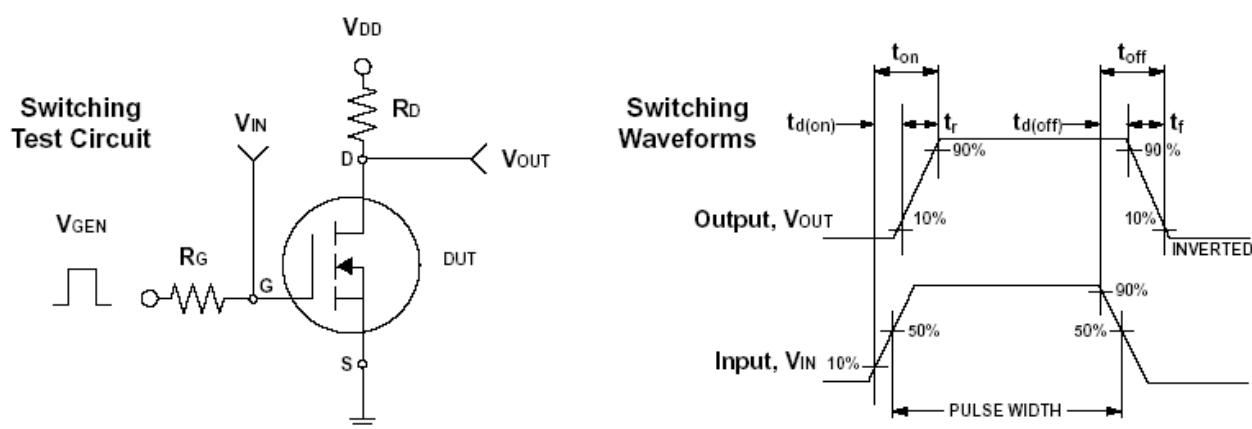
Maximum Ratings and Thermal Characteristics (TA = 25°C unless otherwise noted) 25 °C 极限参数和热特性

Parameter 极限参数	Symbol 符号	Ratings 等级		Unit 单位
		N-沟道	P-沟道	
Drain-Source Voltage 漏源电压	V _{DS}	40	-40	V
Gate-Source Voltage 栅源电压	V _{GS}	±20	±20	V
Continuous Drain Current 连续漏极电流	I _D @ TA=25°C	6.0	-5.0	A
Continuous Drain Current 连续漏极电流	I _D @ TA=70°C	5.0	-4.0	A
Pulsed Drain Current 脉冲漏极电流	I _{DM}	20	-20	A
Total Power Dissipation 功耗	P _D @ TA=25°C	2.1		W
Linear Derating Factor 线性因子		0.016		W/°C
Operating Junction and Storage Temperature Range 使用及储存温度	T _j , T _{stg}	-55 ~ +150		°C

N-Channel Electrical Characteristics ($T_j = 25^\circ\text{C}$ unless otherwise specified) N 沟道电气特性 25°C

Parameter 参数	符号	Test Condition 测试条件	最小值	典型值	最大值	单位
Static 静态参数						
Drain-Source Breakdown Voltage 漏源击穿电压	BV_{DSS}	$V_{\text{GS}} = 0\text{V}, I_{\text{D}} = 250\mu\text{A}$	40			V
Drain-Source On-State Resistance 漏源导通电阻	$R_{\text{DS}(\text{on})}$	$V_{\text{GS}} = 4.5\text{V}, I_{\text{D}} = 5.0\text{A}$		33.0	45.0	mΩ
Drain-Source On-State Resistance 漏源导通电阻	$R_{\text{DS}(\text{on})}$			23.0	31.0	
Gate Threshold Voltage 开启电压	$V_{\text{GS}(\text{th})}$	$V_{\text{DS}} = V_{\text{GS}}, I_{\text{D}} = 250\mu\text{A}$	1	1.8	3	V
Zero Gate Voltage Drain Current 零栅压漏极电流	I_{DSS}	$V_{\text{DS}} = 40\text{V}, V_{\text{GS}} = 0\text{V}$			1	uA
Gate Body Leakage 漏极短路时截止栅电流	I_{GSS}	$V_{\text{GS}} = \pm 20\text{V}, V_{\text{DS}} = 0\text{V}$			± 100	nA
Forward Transconductance 正向跨导	g_{fs}	$V_{\text{DS}} = 5\text{V}, I_{\text{D}} = 5\text{A}$		17	—	S
Dynamic 动态参数						
Total Gate Charge 栅极总电荷	Q_g	$V_{\text{DS}} = 20\text{V}, I_{\text{D}} = 1.5\text{A}$ $V_{\text{GS}} = 10\text{V}$		14.5		nC
Gate-Source Charge 栅-源极电荷	Q_{gs}			1.5		
Gate-Drain Charge 栅-漏极电荷	Q_{gd}			3.5		
Turn-On Delay Time 导通延迟时间	$t_{\text{d}(\text{on})}$	$V_{\text{DD}} = 20\text{V}, R_L = 5\Omega$ $I_{\text{D}} = 1\text{A}, V_{\text{GEN}} = 10\text{V}$ $R_G = 3\Omega$		10.5		ns
Turn-On Rise Time 导通上升时间	t_r			16.05		
Turn-Off Delay Time 关断延迟时间	$t_{\text{d}(\text{off})}$			39		
Turn-Off Fall Time 关断下降时间	t_f			10		
Input Capacitance 输入电容	C_{iss}	$V_{\text{DS}} = 20\text{V}, V_{\text{GS}} = 0\text{V}$ $f = 1.0\text{ MHz}$		745		pF
Output Capacitance 输出电容	C_{oss}			65.7		
Reverse Transfer Capacitance 反向传输电容	C_{rss}			53.35		
Source-Drain Diode 源漏二极管参数						
Max. Diode Forward Current 最大正向电流	I_s				4.3	A
Diode Forward Voltage 正向电压	V_{SD}	$I_s = 1\text{A}, V_{\text{GS}} = 0\text{V}$			1.3	V

Note: Pulse test: pulse width $\leq 300\text{us}$, duty cycle $\leq 2\%$ 注意: 脉冲测试: 脉冲宽度 $\leq 300\text{us}$ 死区 $\leq 2\%$



N-Channel Characteristics Curve N 沟道电气性能特征曲线

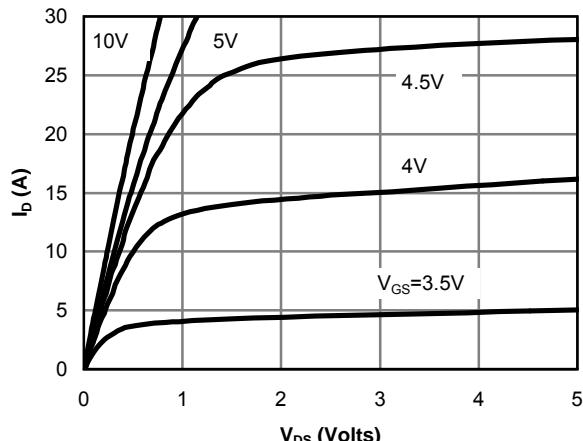


Figure 1: On-Region Characteristics

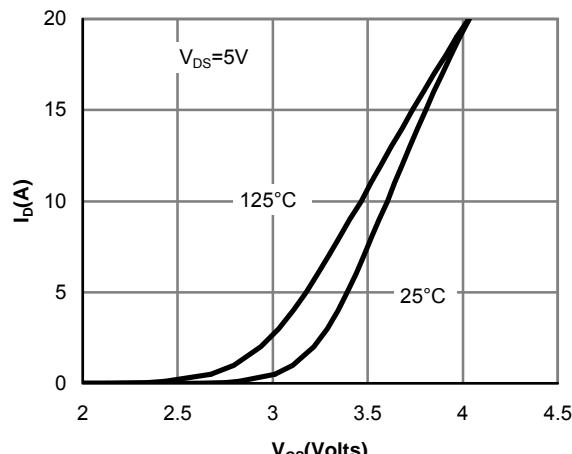


Figure 2: Transfer Characteristics

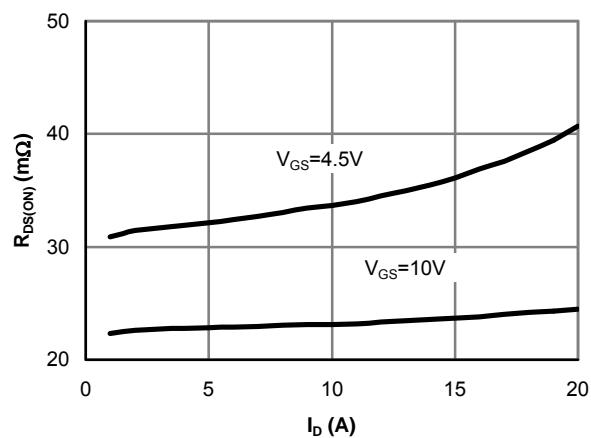


Figure 3: On-Resistance vs. Drain Current and Gate Voltage

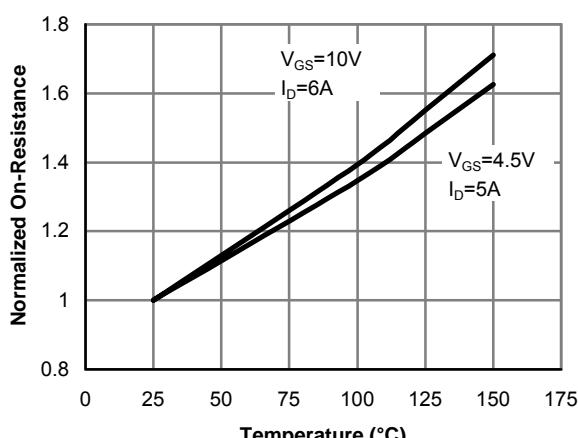


Figure 4: On-Resistance vs. Junction Temperature

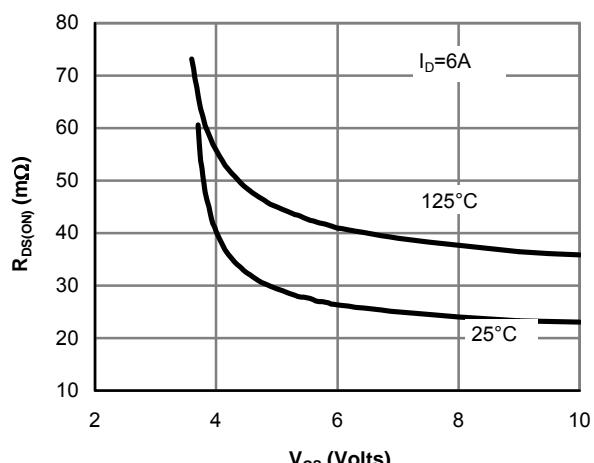


Figure 5: On-Resistance vs. Gate-Source Voltage

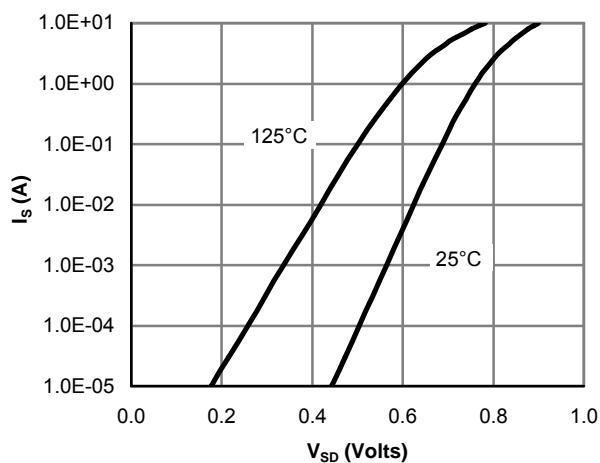


Figure 6: Body-Diode Characteristics

P-Channel Electrical Characteristics ($T_j = 25^\circ\text{C}$ unless otherwise specified) P 沟道电气特性 25°C

Parameter 参数	符号	Test Condition 测试条件	最小值	典型值	最大值	单位
Static 静态参数						
Drain-Source Breakdown Voltage 漏源击穿电压	BV_{DSS}	$V_{GS} = 0\text{V}, I_D = -250\mu\text{A}$	-40			V
Drain-Source On-State Resistance 漏源导通电阻	$R_{DS(on)}$	$V_{GS} = -4.5\text{V}, I_D = -4.0\text{A}$		51	63	$\text{m}\Omega$
Drain-Source On-State Resistance 漏源导通电阻	$R_{DS(on)}$	$V_{GS} = -10\text{V}, I_D = -5.0\text{A}$		35	45	
Gate Threshold Voltage 栅源电压	$V_{GS(th)}$	$V_{DS} = V_{GS}, I_D = -250\mu\text{A}$	-1	-1.7	-3	V
Zero Gate Voltage Drain Current 0 棚压漏极电流	I_{DSS}	$V_{DS} = -40\text{V}, V_{GS} = 0\text{V}$			-1	μA
Gate Body Leakage 漏极短路时截止栅电流	I_{GSS}	$V_{GS} = \pm 20\text{V}, V_{DS} = 0\text{V}$			± 100	nA
Forward Transconductance 正向跨导	g_{fs}	$V_{DS} = -5\text{V}, I_D = -5\text{A}$		5		S
Dynamic³⁾ 动态参数						
Total Gate Charge 栅极总电荷	Q_g	$V_{DS} = -20\text{V}, I_D = -1.5\text{A}$ $V_{GS} = -10\text{V}$		21.52		nC
Gate-Source Charge 栅-源极电荷	Q_{gs}			2.4		
Gate-Drain Charge 栅-漏极电荷	Q_{gd}			4.82		
Turn-On Delay Time 导通延迟时间	$t_{d(on)}$	$V_{DD} = -20\text{V}, R_L = 5\Omega$ $I_D = -1\text{A}, V_{GEN} = -10\text{V}$ $R_G = 3\Omega$		15.08		ns
Turn-On Rise Time 导通上升时间	t_r			14.53		
Turn-Off Delay Time 关断延迟时间	$t_{d(off)}$			51		
Turn-Off Fall Time 关断下降时间	t_f			14.8		
Input Capacitance 输入电容	C_{iss}	$V_{DS} = -20\text{V}, V_{GS} = 0\text{V}$ $f = 1.0\text{MHz}$		1238		pF
Output Capacitance 输出电容	C_{oss}			99		
Reverse Transfer Capacitance 反向传输电容	C_{rss}			67.5		
Source-Drain Diode 源漏二极管参数						
Max. Diode Forward Current 最大正向电流	I_S				-2.3	A
Diode Forward Voltage 正向电压	V_{SD}	$I_S = -2.3\text{A}, V_{GS} = 0\text{V}$			-1.2	V

P-Channel

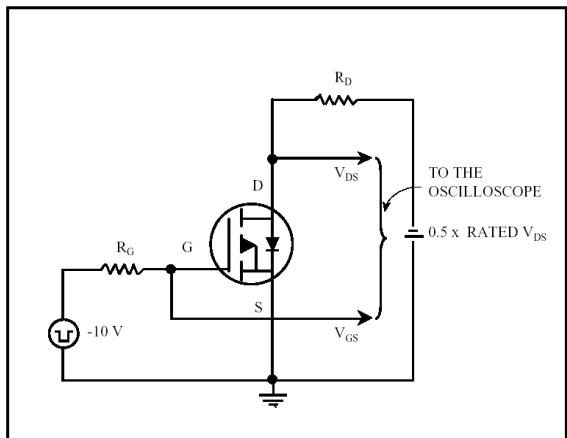


Fig 13. Switching Time Circuit

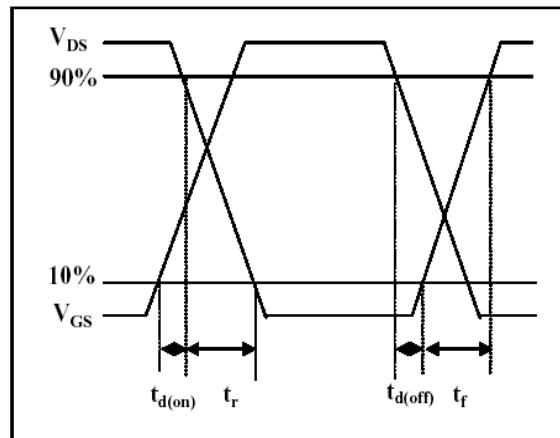


Fig 14. Switching Time Waveform

P-Channel Characteristics Curve P 沟道电气性能特征曲线

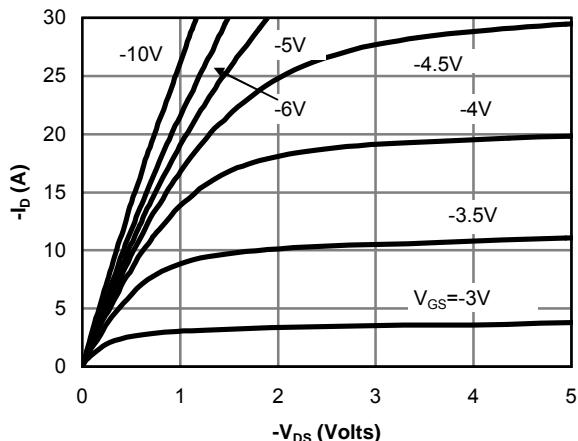


Figure 1: On-Region Characteristics

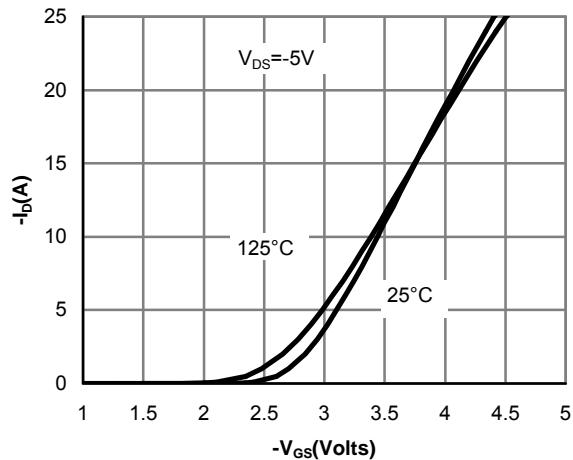


Figure 2: Transfer Characteristics

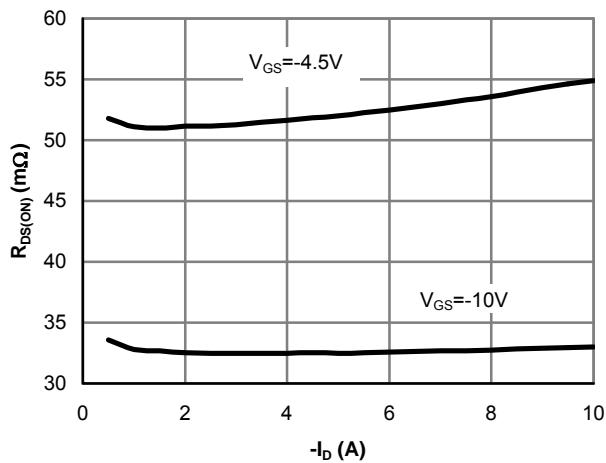


Figure 3: On-Resistance vs. Drain Current and Gate Voltage

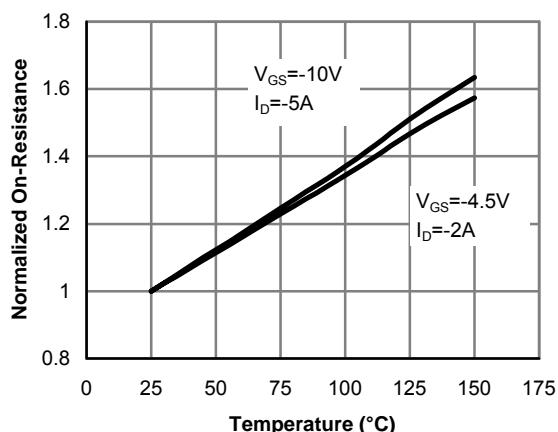


Figure 4: On-Resistance vs. Junction Temperature

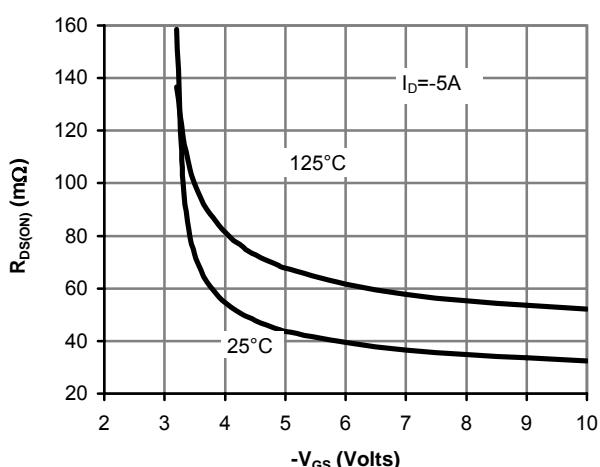


Figure 5: On-Resistance vs. Gate-Source Voltage

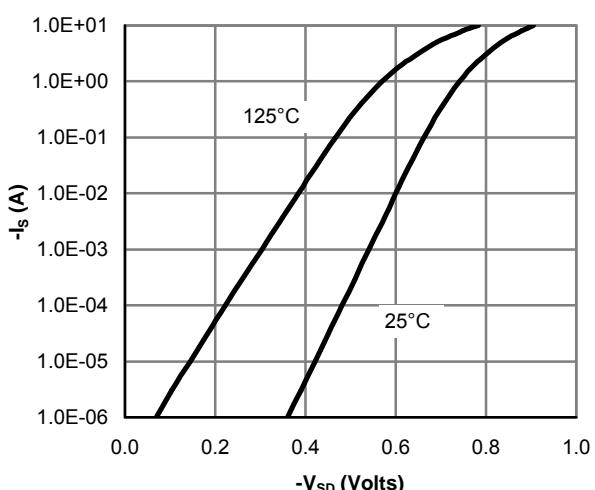


Figure 6: Body-Diode Characteristics